

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Nelson et al.

Appl. No.: 09/841,187

Filed: April 25, 2001

For: Method and System for Improving Focus Accuracy in a Lithography

**System** 

Confirmation No.: 3650

Art Unit: 2851

Examiner: Alan A. Matthews

Atty. Docket: 1857.0350000

## Amendment and Reply Under 37 C.F.R. § 1.111

Commissioner for Patents PO Box 1450 Alexandria, VA 22313-1450

Sir:

In reply to the Office Action dated August 11, 2004, (PTO Prosecution File Wrapper Paper No./Mail Date 20040806), Applicants submit the following Amendment and Remarks. This Amendment is provided in the following format:

- (A) Each section begins on a separate sheet;
- (B) Starting on a separate sheet, amendments to the specification by presenting replacement paragraphs marked up to show changes made;
- (C) Starting on a separate sheet, a complete listing of all of the claims:
  - in ascending order;
  - with status identifiers; and
  - with markings in the currently amended claims;
- (D) Starting on a separate sheet, the Remarks.

It is not believed that extensions of time or fees for net addition of claims are required beyond those that may otherwise be provided for in documents accompanying this paper. However, if additional extensions of time are necessary to prevent

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abandonment of this application, then such extensions of time are hereby petitioned under 37 C.F.R. § 1.136(a), and any fees required therefor (including fees for net addition of claims) are hereby authorized to be charged to our Deposit Account No. 19-0036.



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Admitted only in Maryland Admitted only in Virginia Practice Limited to Federal Agencies

September 20, 2004

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Art Unit 2851

Commissioner for Patents PO Box 1450 Alexandria, VA 22313-1450

Re:

U.S. Non-Provisional Patent Application

Application No. 09/841,187; Filed: April 25, 2001

Method and System for Improving Focus Accuracy in a Lithography

System

Inventors:

Nelson et al.

Our Ref:

1857.0350000

Sir:

Transmitted herewith for appropriate action are the following documents:

- Amendment and Reply Under 37 C.F.R. 1.111; and 1.
- 2. One (1) return postcard.

It is respectfully requested that the attached postcard be stamped with the date of filing of these documents, and that it be returned to our courier. In the event that extensions of time are necessary to prevent abandonment of this patent application, then such extensions of time are hereby petitioned.

The U.S. Patent and Trademark Office is hereby authorized to charge any fee deficiency, or credit any overpayment, to our Deposit Account No. 19-0036.

Respectfully submitted,

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MKH/jmh 312676

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